## **RF EXPOSURE EVALUATION**

According to FCC 1.1310: The criteria listed in the following table shall be used to evaluate the environment impact of human exposure to radio frequency(RF) Radiation as specified in §1.1307(b)

Frequency range (MHz)	Electric field strength (V/m)	Magnetic field strength (A/m)	Power density (mW/cm <sup>2</sup> )	Averaging time (minutes)			
(A) Limits for Occupational/Controlled Exposure							
0.3-3.0	614	1.63	*100	6			
3.0-30	1842/1	4.89/1	*900/f <sup>2</sup>	6			
30-300	61.4	0.163	1.0	6			
300-1,500			f/300	6			
1,500-100,000			5	6			
(B) Limits for General Population/Uncontrolled Exposure							
0.3-1.34	614	1.63	*100	30			
1.34-30	824/1	2.19/1	*180/f <sup>2</sup>	30			
30-300	27.5	0.073	0.2	30			
300-1,500			f/1500	30			
1,500-100,000			1.0	30			

	Limits for	or Maximum	Permissible	Exposure	(MPE)
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f = frequency in MHz \* = Plane-wave equivalent power density

MPE Calculation Method

$$\mathsf{E}(\mathsf{V/m}) = \frac{\sqrt{30*P*G}}{d}$$

Power Density: 
$$Pd$$
 (W/m<sup>2</sup>) =  $\frac{E^2}{377}$ 

E = Electric field (V/m)

P = Average RF output power (W)

G = EUT Antenna numeric gain (numeric)

d = Separation distance between radiator and human body (m)

The formula can be changed to

$$Pd = \frac{30 * P * G}{377 * D^2}$$

From the EUT RF output power, the minimum mobile separation distance, d=0.2m, as well as the gain of the used antenna, the RF power density can be obtained.

## Measurement Result

Z-wave Antenna Type: stamped metal Antenna antenna gain: -0.24 dBi

Transmit power

	Frequency	Max Output power	EIRP power		
	(MHz)	(dBuV/m)	(dBm)		
	916.00	87.0	-8.23		

EIRP=E-104.8+20log(D)

Maximum Permissible Exposure:

Channel Freq. (MHz)	modulation	EIRP power (dBm)	EIRP Power (mW)	Tune-up power (dBm)	Max tune-up power (dBm)	Evaluation result (mW/cm2)	Power density Limits (mW/cm2)
916.00	GFSK	-8.23	0.15	-8±1	-7.00	0.000040	0.611

## **Conclusion:**

For the max result : 0.000040≤ 0.611 for Max Power Density, compliance RF exposure..

## Signature:

Date: 2024-08-05

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